IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants:

Geun Su Lee et al.

Serial No.:

10/723,029

Filed:

November 26, 2003

Title:

Cleaning Solution for Photoresist and Method for Forming Pattern

Using the Same

Group Art Unit: 1751

Examiner:

Gregory E. Webb

Attorney Docket No.: 30205/39714

I hereby certify that this paper (along with any paper referred to as being attached or enclosed) is being transmitted via EFS-Web to the U.S. Patent and Trademark Office on **December 27, 2006**.

Sandib H. Patel (Reg. No. 43,848)

Attorney for Applicants

PETITION UNDER 37 CFR § 1.136(a)

Mail Stop Amendment Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Dear Sir:

Applicants, by their attorney, petition for a one-month extension of time to file a response to the August 28, 2006, official action in the above-captioned application.

Submitted herewith is payment in the amount of \$120.00 to cover the patent application processing fee required under 37 CFR § 1.17(a)(1). Any additional required fee may be charged to Deposit Account No. 13-2855. Any overpayment should be refunded to the undersigned attorney's law firm at the address indicated below.

Respectfully submitted,

MARSHALL, GERSTEIN & BORUN LLP

December 27, 2006

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